

Amendments to the Specification:

Please replace the paragraph beginning at page 26, line 15 as with the following amended paragraph:

First, the hole transporting region 514 consisting solely of TPD is formed to a thickness of 30nm. Then, evaporation of BAlq as a host material to the light emitting material is started also at an evaporation rate of 3 Å/s with keeping the evaporation rate of TPD at 3 Å/s. In other words, the first mixed region 517 containing TPD and [[Alq]] BAlq at a ratio of 1 : 1 is formed by coevaporation. The first mixed region is 10 nm in thickness.